

MNC 2011 (October 24-27, ANA Hotel Kyoto, Japan) Schedule

Monday, October 24

Room B (2F Suzaku)	Technical Seminar in Japanese Registration Desk (2FLobby)
13:30-17:00 MNC 2011 Technical Seminar in Japanese	October 24, 12:30 - 16:30
Room P (2F Heian 3,4)	Conference Registration Desk (2FLobby)
17:00-19:00 Get Together Party	October 24, 16:30- 18:30 October 25, 8:30 - 18:00 October 26, 8:30 - 19:00 October 27, 8:30 - 16:00

Tuesday, October 25

Room A (2F Heian)		October 26, 8:30 - 19:00 October 27, 8:30 - 16:00
25P-1:Opening Session 9:30-12:10 Opening Remark and 2010 Award Presentation Sadao Wasaka (NEDO, Japan) Naotaka Sumihiro (LEAP, Japan) Loh Kian Ping (National Univ. of Singapore, Singapore)		
Lunch		
Room A (2F Heian 1)	Room B (2F Suzaku 1)	Room C (2F Suzaku 2)
25A-2: 13:40-15:30 Symp. A: Graphene I	25B-2: 13:40-15:50 Microsystem Technology and MEMS I	25C-2: 14:00-15:50 BioMEMS, Lab on a Chip I
Room P (2F Heian 3,4)		
Coffee Break		
Room A (2F Heian)	Room B (2F Suzaku 1)	Room C (2F Suzaku 2)
25A-3: 15:50-17:30 Symp. A: Graphene II	25B-3: 16:05-17:55 Microsystem Technology and MEMS II	25C-3: 16:10-17:10 BioMEMS, Lab on a Chip II
25A-2.3 Author's Interview: 17:30-17:40	25B-2. 3 Author's Interview: 17:55-18:05	25C-2. 3 Author's Interview: 17:10-17:20

Wednesday, October 26

Room A (2F Heian)	Room B (2F Suzaku 1)	Room C (2F Suzaku 2)
26A-4: 9:00-10:50 Nano Carbon I	26B-4: 9:00-11:10 Symp. B: Molecular Modification/molecular Self-assembly for Micro/nano-structure 26B-4 Author's Interview: 11:10-11:20	26C-4: 9:00-11:10 Novel Transistors
Room P (2F Heian 3,4)		
Coffee Break		
Room A (2F Heian 1)	Room B (2F Suzaku 1)	Room C (2F Suzaku 2)
26A-5: 11:05-12:25 Nano Carbon II	26B-5: 11:25-12:35 Nanomaterials I	26C-5: 11:25-12:25 New Functional Devices
26A-4, 5 Author's Interview: 12:25-12:35		26C-4, 5 Author's Interview: 12:25-12:35
Lunch		
26A-6: 14:00-15:50 Lithography and Metrology	26B-6: 14:05-15:40 Nanomaterials II	26C-6: 14:00-15:50 New Conceptual Devices
26A-6 Author's Interview: 15:50-16:00	26B-5, 6 Author's Interview: 15:40-15:50	26C-6 Author's Interview: 15:50-16:00
Room P (2F Heian 3,4)		
26P-7: 16:00-18:00 Poster Session I Lithography and Metrology, Nanocarbon, Nanodevices, Nanofabrication, Nanomaterials, Nanoimprint, Nanoprint and Rising Lithography, Bio MEMS, Lab on a Chip and Microsystem Technology and MEMS		
Room A and P (2F Epmire 1,2)		
18:30-20:30 Banquet		

Thursday, October 27

Room A (2F Heian 1)	Room B (2F Suzaku 1)	Room C (2F Suzaku 2)
27A-8: 9:00-10:30 Nanoimprint, Nanoprint and Rising Lithography I	27B-8: 9:00-10:40 Nanomaterials III	27C-8: 9:00-10:20 Nanofabrication I
Room P (2F Heian 3,4)		
Coffee Break		
Room A (2F Heian 1)	Room B (2F Suzaku 1)	Room C (2F Suzaku 2)
27A-9: 10:45-12:15 Nanoimprint, Nanoprint and Rising Lithography II	27B-9: 10:55-12:15 Nanomaterials IV	27C-9: 10:35-12:25 Nanofabrication II
27A-8, 9 Author's Interview: 12:15-12:25	27B-8, 9 Author's Interview: 12:15-12:25	27C-8, 9 Author's Interview: 12:25-12:35
Lunch		
27A-10: 13:50-15:20 Resists Materials and Processing	27B-10: 13:50-15:20 Nano-Tool	27C-10: 14:00-15:20 Nanofabrication III
27A-10 Author's Interview: 15:20-15:30	27B-10 Author's Interview: 15:20-15:30	27C-10 Author's Interview: 15:20-15:30
Room P (2F Heian 3,4)		
27P-11: 15:30-17:30 Poster Session II Resist Materials and Processing, Nanocarbon, Nanodevices, Nanofabrication, Nanomaterials, Nano-Tool, Nanoimprint, Nanoprint and Rising Lithography, BioMEMS, Lab on a Chip and Microsystem Technology and MEMS		